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PCN # 253
Notification Date:
March 8, 2024

Product / Process Change Notice

Devices affected:

The CBRDFSH1-40 Schottky bridge rectifier manufactured in the BR DFN case.

Extent of change:

Change in wafer fab, resulting in change in die size from 32 x 32 mils to 35 x 35 mils (see Table 1).

Reason for change:

As part of Central Semiconductor’s supply chain risk mitigation initiative, and in an effort to ensure an undisrupted supply of product, a change in wafer fabrication site is being made for the products referenced above. Product specifications, quality and reliability are not impacted by this change.

Effect of change:

This change does not affect the fit, form or function of the devices.

Earliest effective date of change:

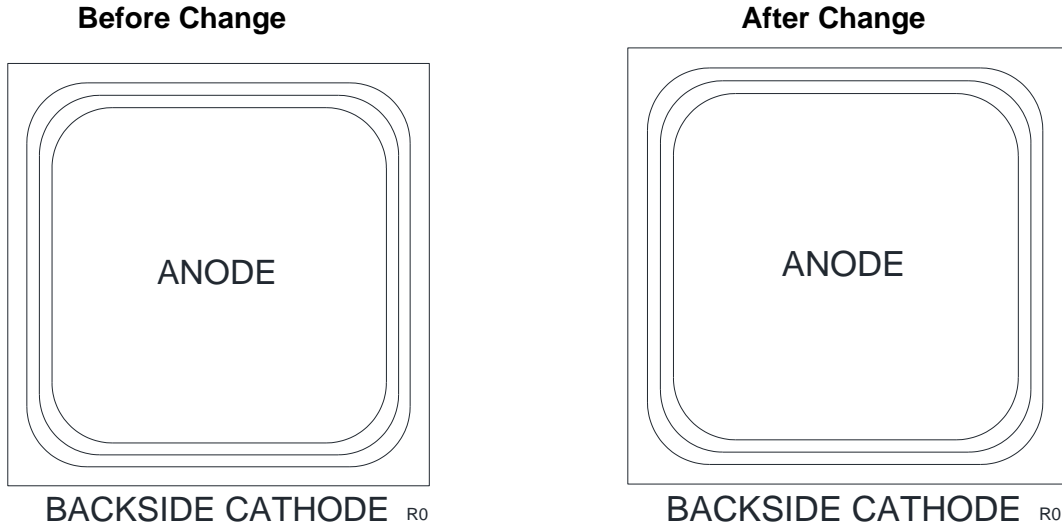
March 8, 2024

Qualification data:

| Test | Condition | Failure rate |
|---|---|--------------|
| High Temperature Storage Life (HTSL) | 150°C (-0/+10)°C, 1000 hours. JESD22-A103 | 0/77 |
| Temperature Cycling (TC) | T= -65°C to +150°C 1000 cycles. Dwell time = 15 min. JESD22-A104 & MIL-STD-750 TM1051 | 0/77 |
| High Temperature Reverse Bias (HTRB) | T=125°C, t=1000 hours, Bias per device data sheet JESD22-A108 | 0/77 |
| Thermal Shock (TS) | 100 cycles, dwell time = 5 min, -65°C to +150°C, max transfer time = 20 sec. JESD22-A106 | 0/77 |
| Unbiased Highly Accelerated Temperature and Humidity Stress Test (UHAIST) | T = 110°C, RH = 85%, t = 264 hrs JESD22-A110 | 0/77 |
| Highly Accelerated Temperature and Humidity Stress Test (HAST) | T = 110°C, RH = 85%, and t = 264 hours. Bias conditions per device specification sheet. JESD22-A110 | 0/77 |

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Table 1:



| | |
|------------------------|--------------|
| Die Size | 32 x 32 MILS |
| Die Thickness | 10 MILS |
| Anode Bonding Pad Size | 29 x 29 MILS |
| Top Side Metalization | Ti/Ni/Ag |
| Back Side Metalization | Ti/Ni/Ag |

| | |
|------------------------|------------------|
| Die Size | 35 x 35 MILS |
| Die Thickness | 11.8 MILS |
| Anode Bonding Pad Size | 31.8 X 31.8 MILS |
| Top Side Metalization | TiW/TiNi/Ag |
| Back Side Metalization | Ti/Ni/Ag |

As per JEDEC standard JESD46, Customer Notification of Product/Process Changes by Solid-State Suppliers, a lack of acknowledgement of a PCN within thirty (30) days constitutes acceptance of the change.

The undersigned acknowledges and accepts Central Semiconductor's Product/Process Change Notification (PCN).

| | |
|---------------|--|
| Company Name: | |
| Address: | |
| | |
| | |
| Printed Name: | |
| Title: | |
| Signature: | |
| Date: | |